

Special Issue

AI-Driven Safe and High-Quality Development in Process Industries

Message from the Guest Editors

This Special Issue on “AI-Driven Safe and High-Quality Development in Process Industries” seeks high-quality works focusing on the latest novel developments in process systems engineering. Topics include, but are not limited to, the following:

- Intelligent methods and applications in process engineering;
- Application and practice of large models in process industry;
- Process simulation, analysis, optimization and monitoring;
- Risk analysis, fundamental safety theory and practice;
- Development and application of information technology integration.

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Editor-in-Chief

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